



Heller Ehrman White & McAuliffe LLP
Title: "PROCESS FOR DETERMINATION OF
OPTIMIZED EXPOSURE CONDITIONS FOR
TRANSVERSE DISTORTION MAPPING"
Inventor(s): A. Smith et al.
Application No.: 10/800,110 – Filed: 03/12/2004
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1/23

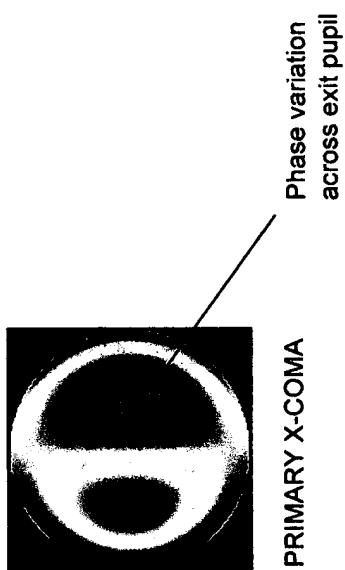


Figure 1a

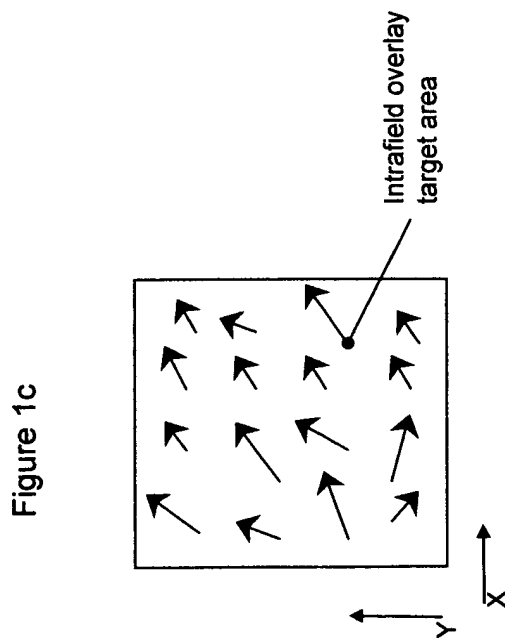
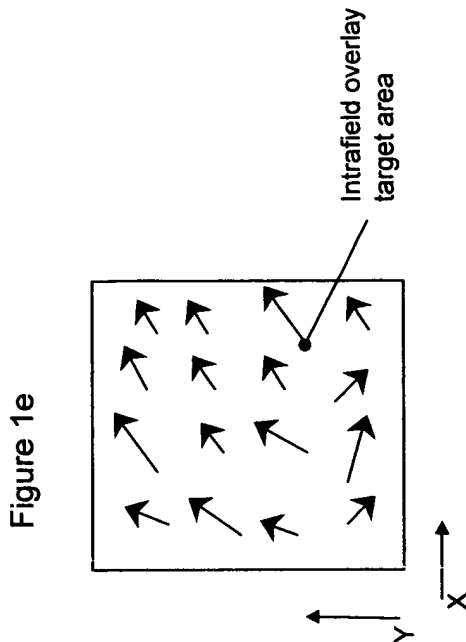
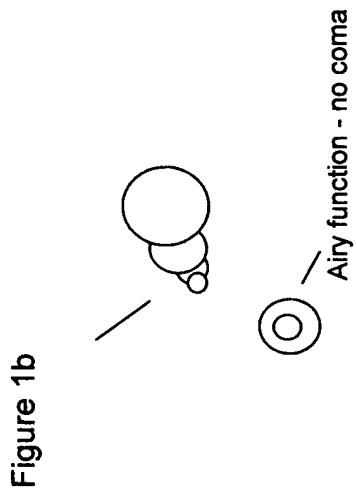
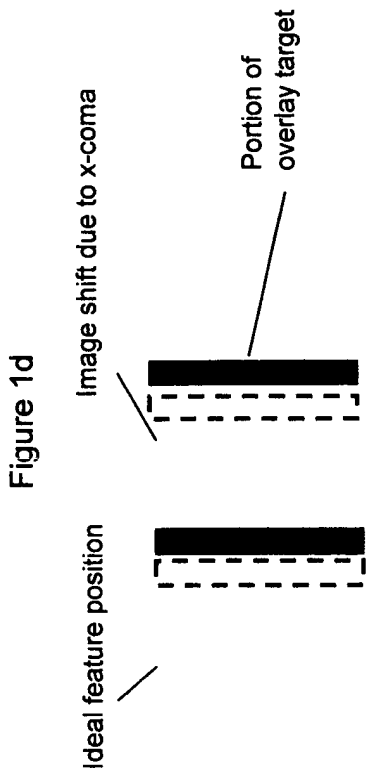


Figure 2a

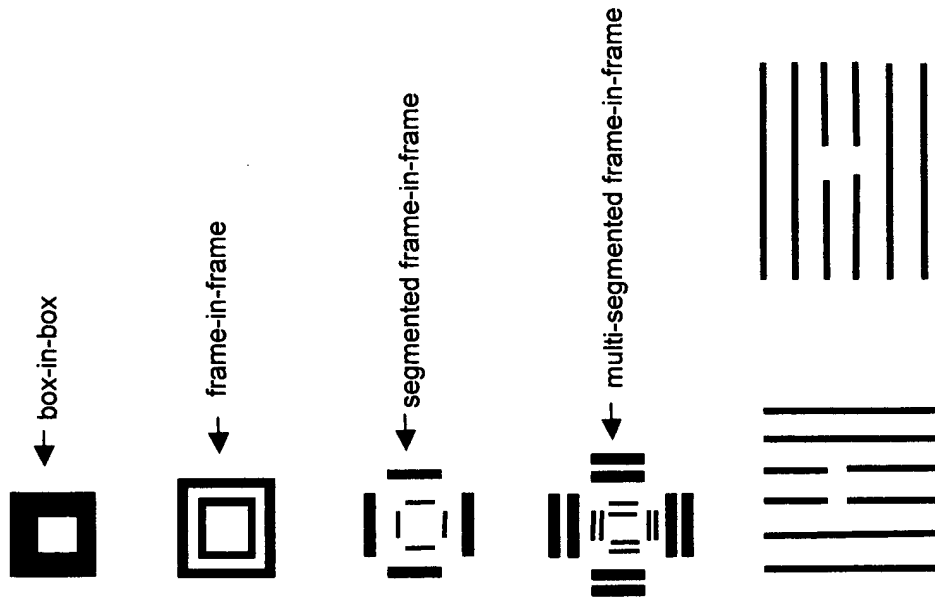
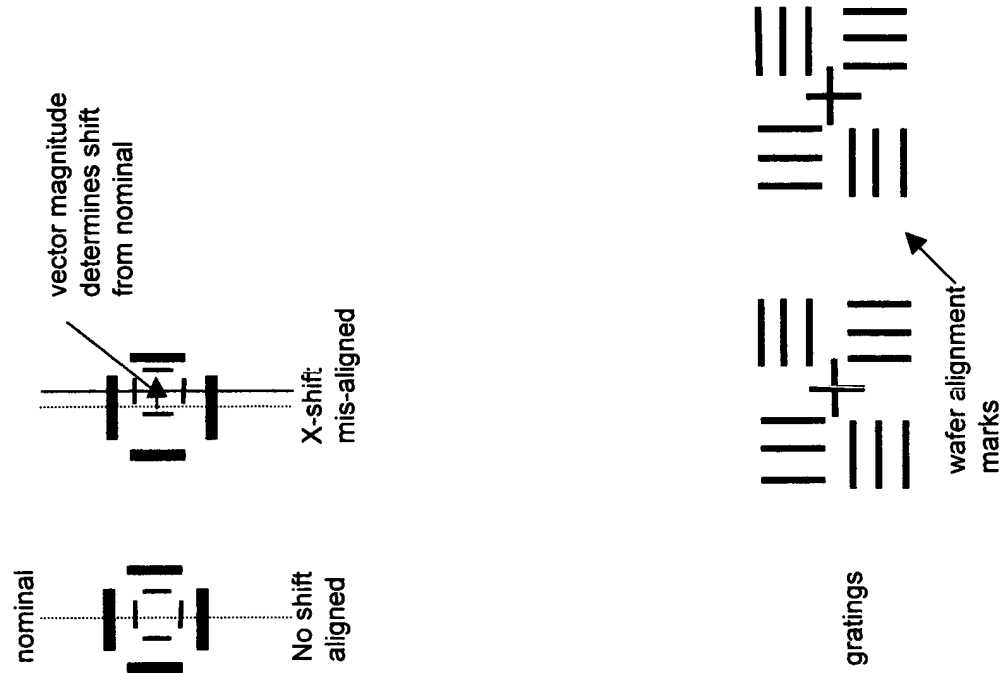


Figure 2b



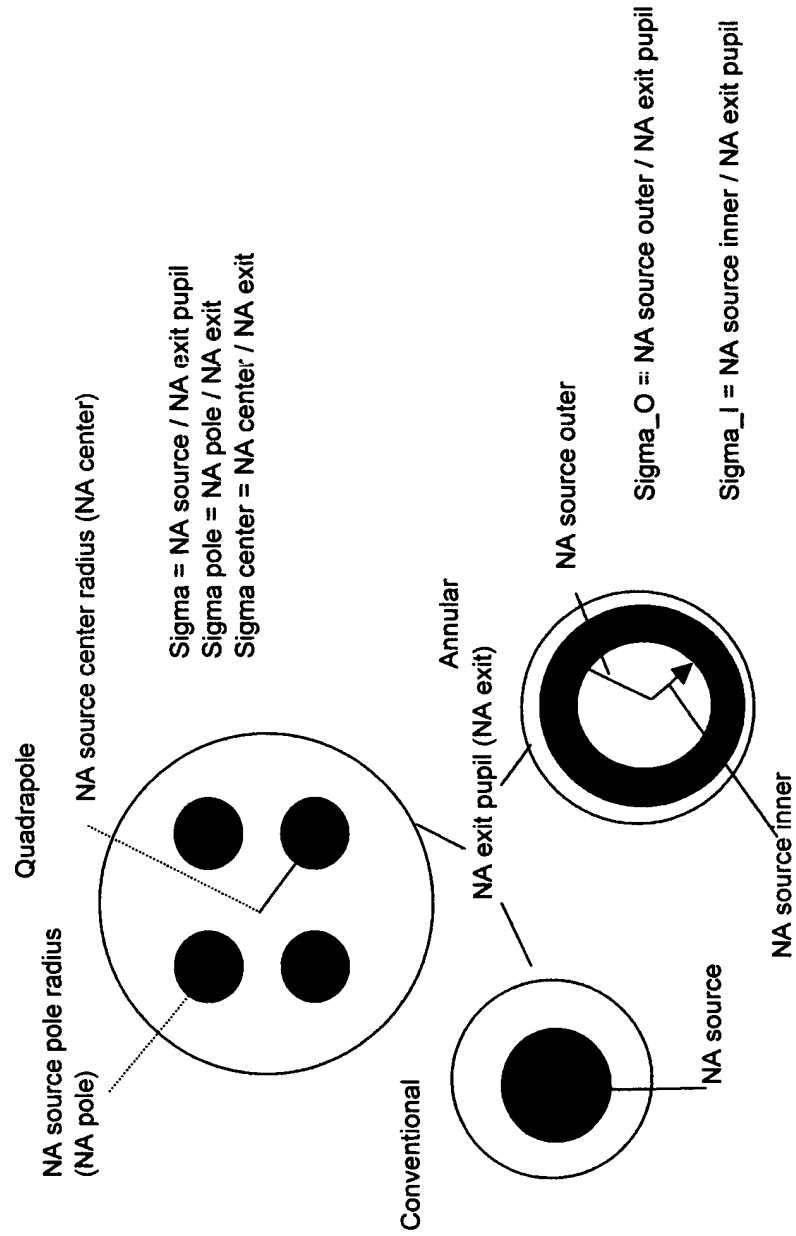


Figure 3

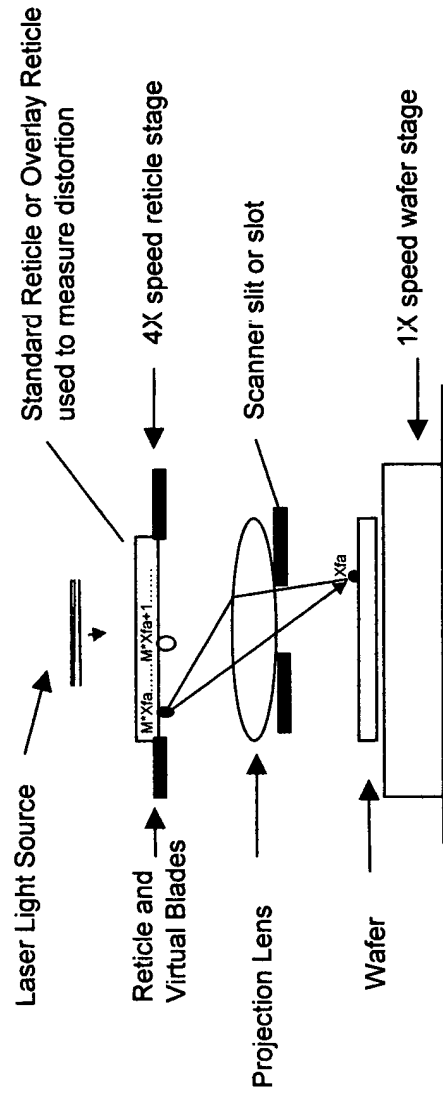


Figure 4a

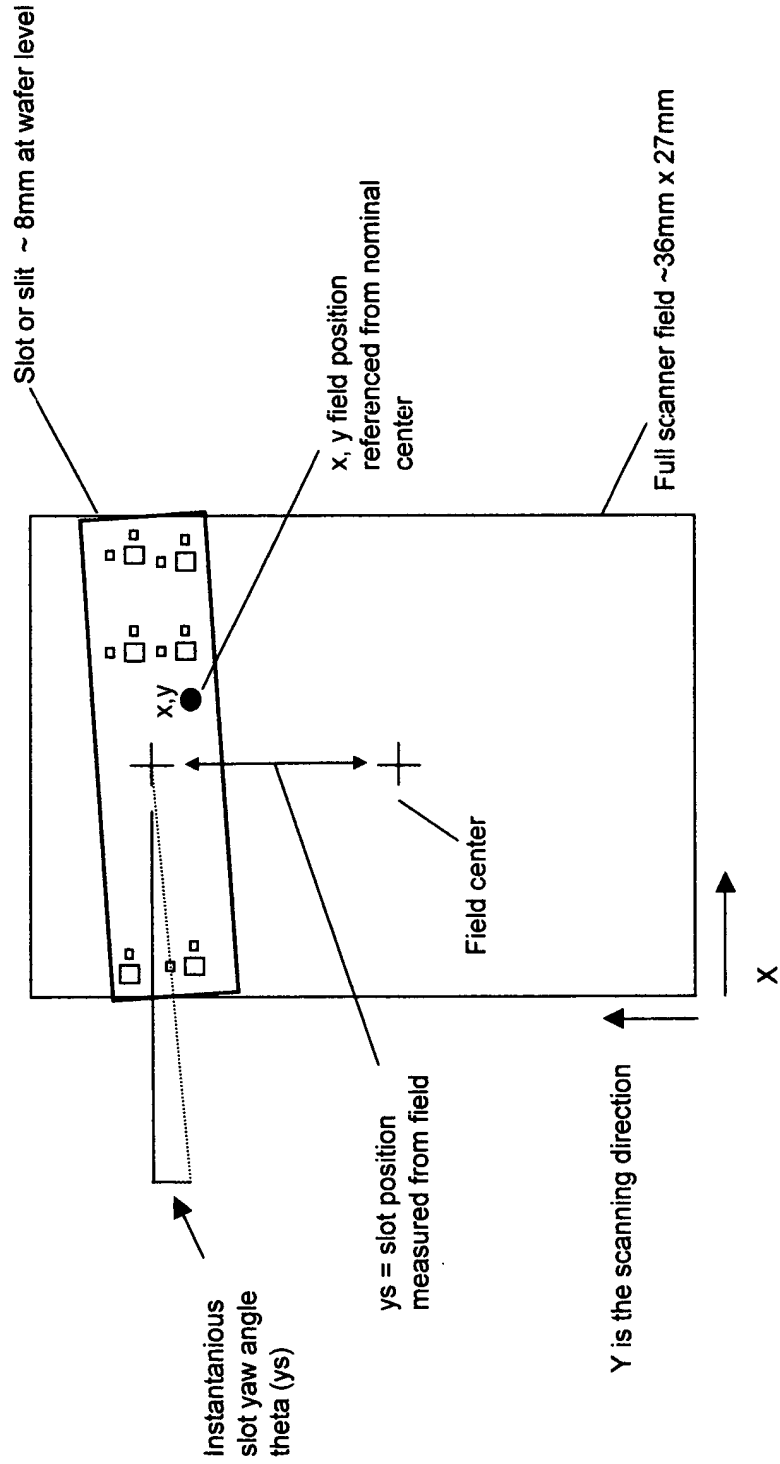
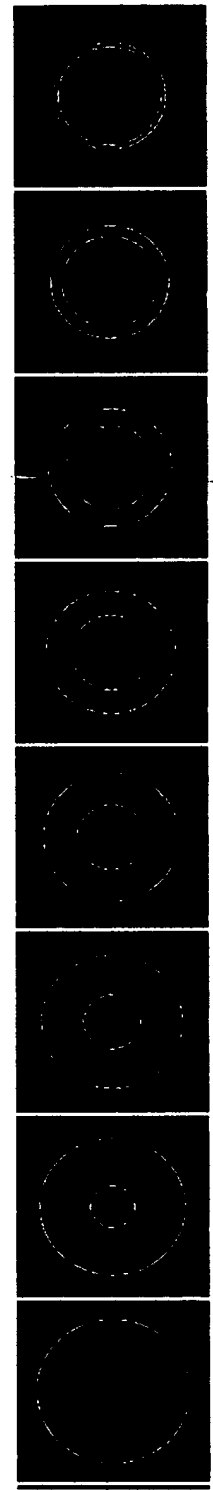


Figure 4b

1um space/4um pitch
400nm resist Threshold model,
E/Eo = 3, focus =150nm

SOURCE SHAPES IN GENERALLY ACCESSIBLE OR 'PRACTICAL'
REGION. PRACTICAL REGION IS SIGMA_O < 0.8 AND 0.25 < EPS <
0.75

NA = 0.60, LAMBDA = 248NM



SIGMA_O	0.836	0.797	0.772	0.746	0.714	0.684	0.653	0.621
SIGMA_I	0	0.239	0.309	0.373	0.428	0.479	0.522	0.559
EPS	0	0.3	0.4	0.5	0.6	0.7	0.8	0.9

EPS = fractional size of hole in source = SIGMA_I / SIGMA_O

Figure 5a

1um space/4um pitch
 400nm resist, resist threshold model,
 E/E0 = 3, focus = 150nm into resist

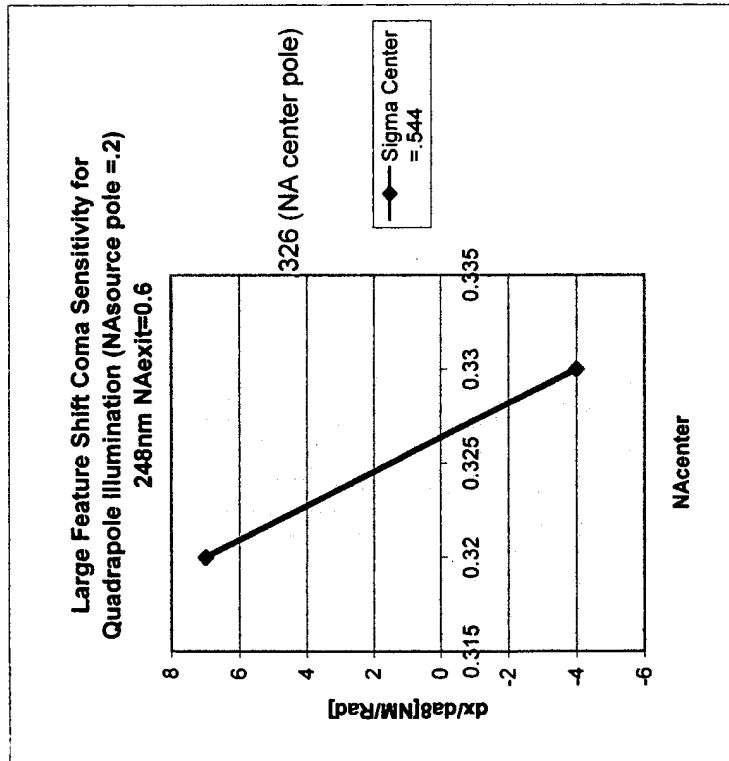


Figure 5b

Figure 6a

Wavelength	NA exit	NA pole	NA center	Sigma Pole	Sigma Center
365nm	0.6	0.2	0.3270	0.3333	0.5450
248nm	0.6	0.2	0.3263	0.3333	0.5438
193nm	0.6	0.2	0.3232	0.3333	0.5387
157nm	0.6	0.2	0.3189	0.3333	0.5315

Figure 6b

Wavelength	NA exit	NA pole	NA center	Sigma Pole	Sigma Center
365nm	0.9	0.2	0.4995	0.2222	0.5550
248nm	0.9	0.2	0.4818	0.2222	0.5353
193nm	0.9	0.2	0.4725	0.2222	0.5250
157nm	0.9	0.2	0.4719	0.2222	0.5243

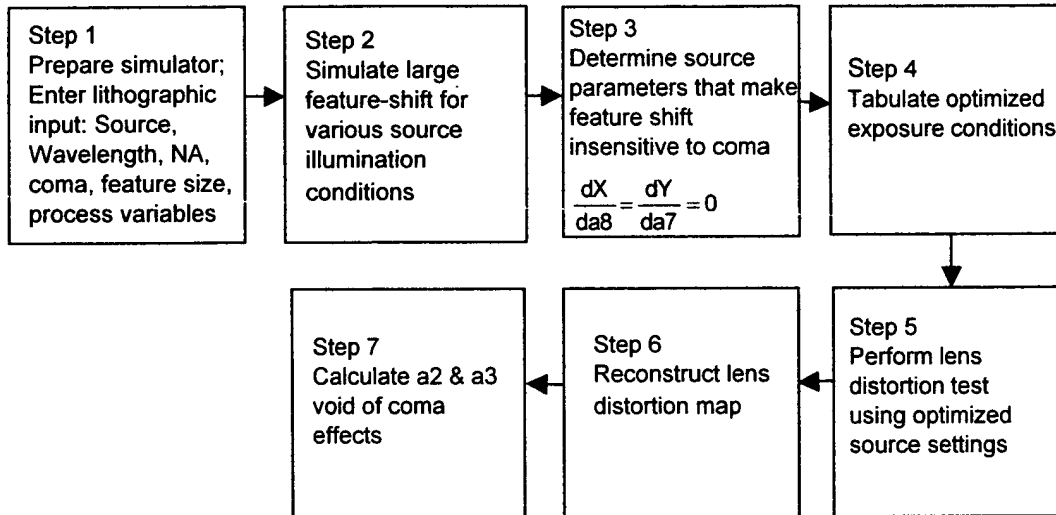


Figure 7a

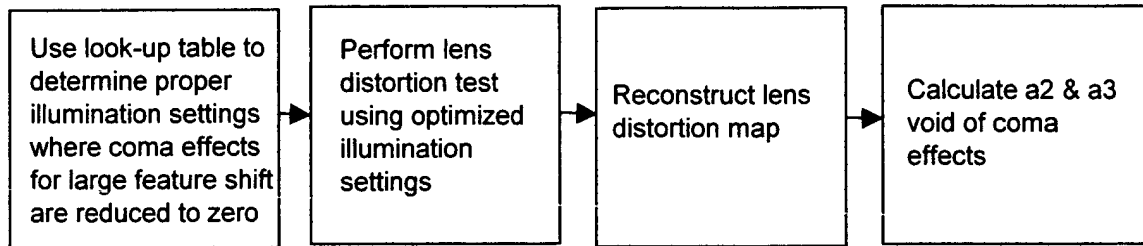


Figure 7b

1um space/4um pitch
 400nm resist, resist threshold model, E/E0 = 3
 focus = 150nm

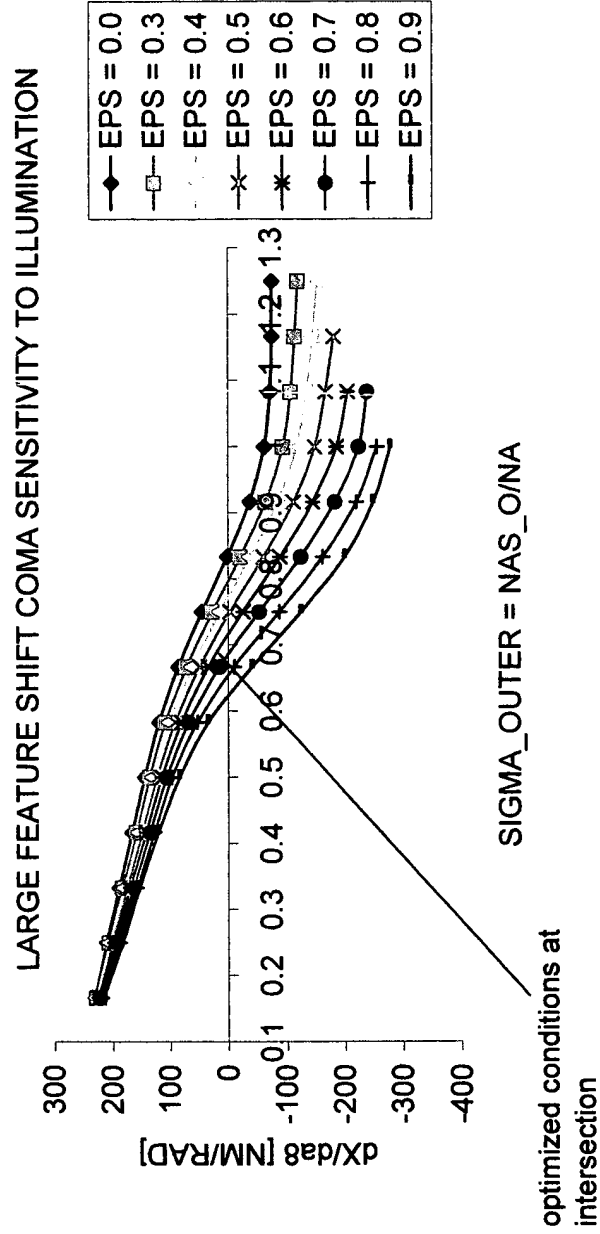


Figure 8a

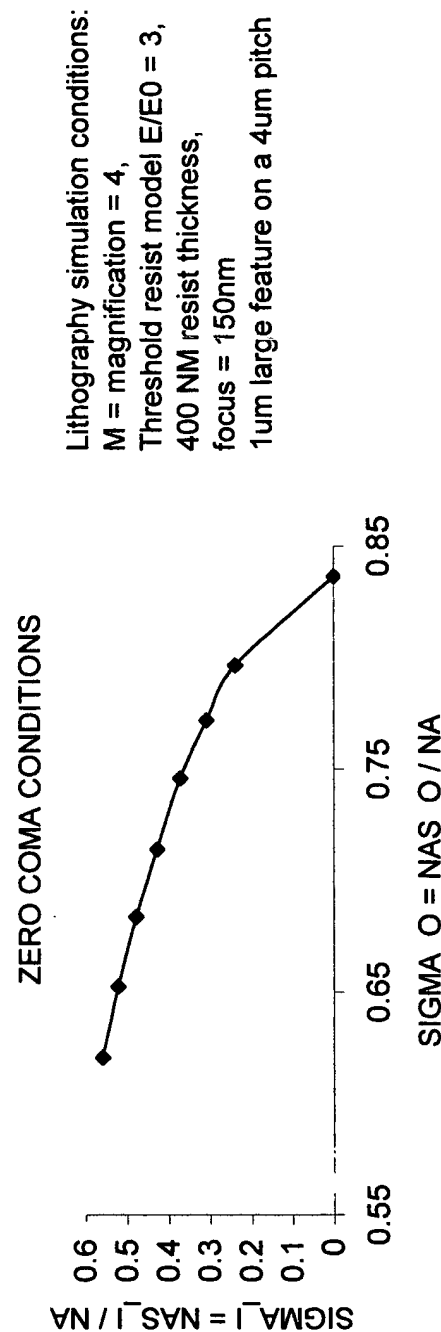


Figure 8b

1um space/4um pitch
 400nm resist, resist
 threshold model, E/E0 = 3,
 focus = 150nm

LARGE FEATURE SHIFT COMA SENSITIVITY TO ILLUMINATION

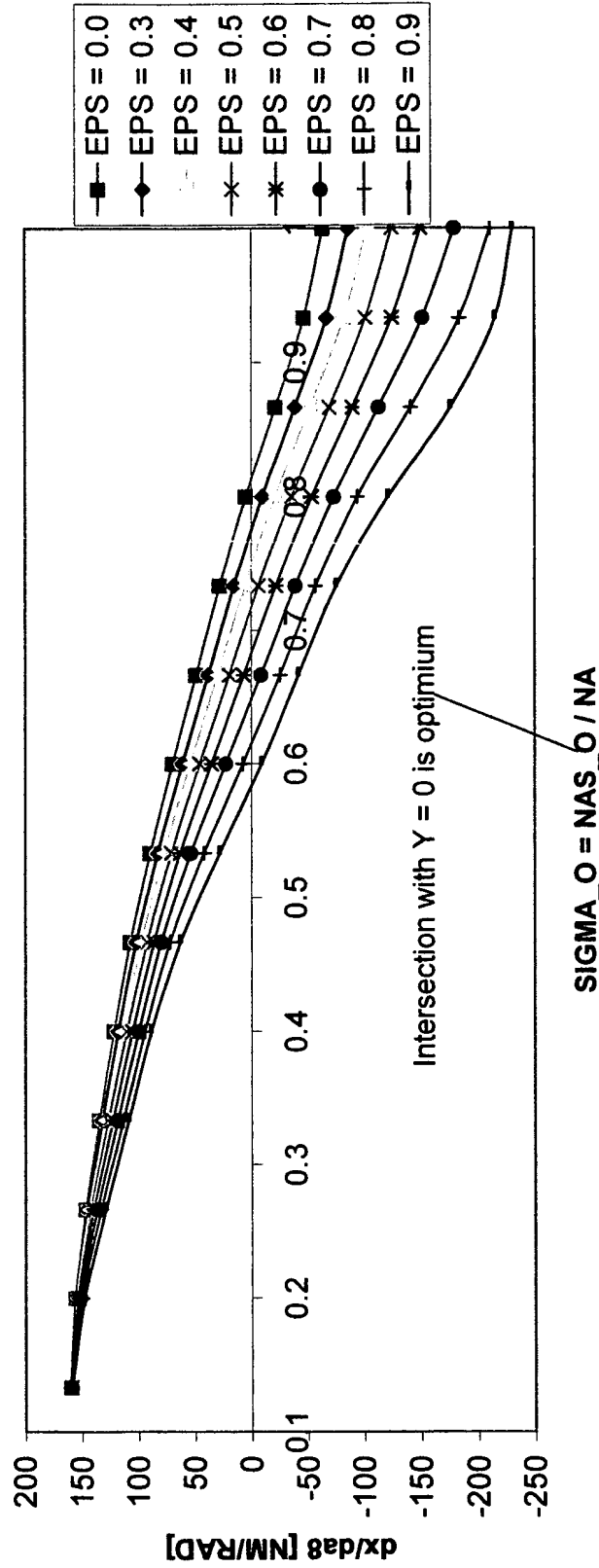


Figure 9a

Lithography simulation conditions:
 M = magnification = 4,
 Threshold resist model E/E0 = 3,
 400 NM resist thickness,
 focus = 150nm
 1um large feature on a 4um pitch

ZERO COMA CONDITIONS
LAMBDA = 193 NM

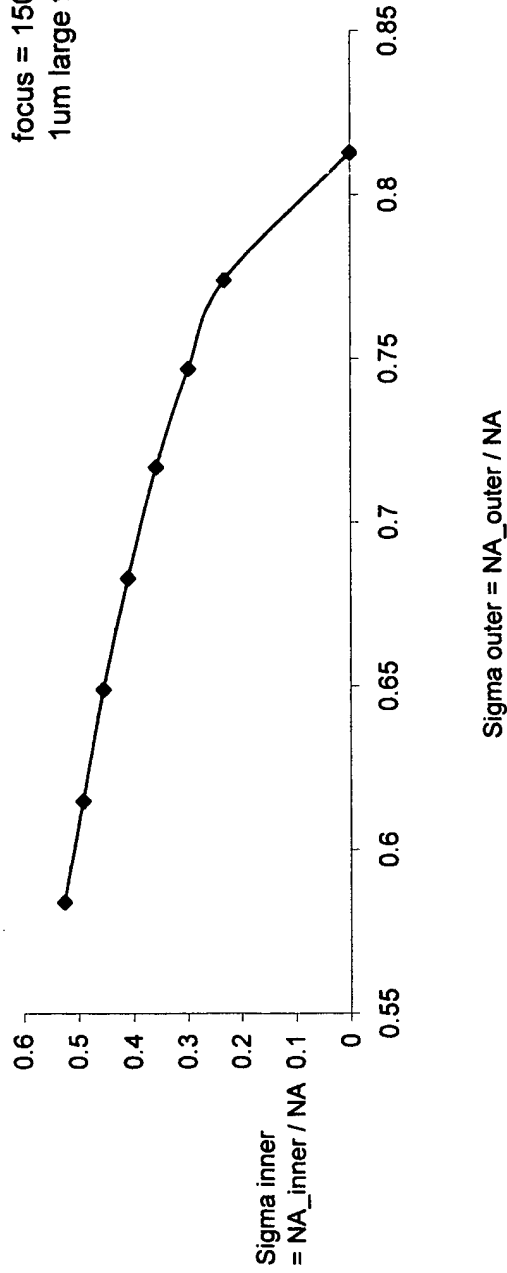


Figure 9b

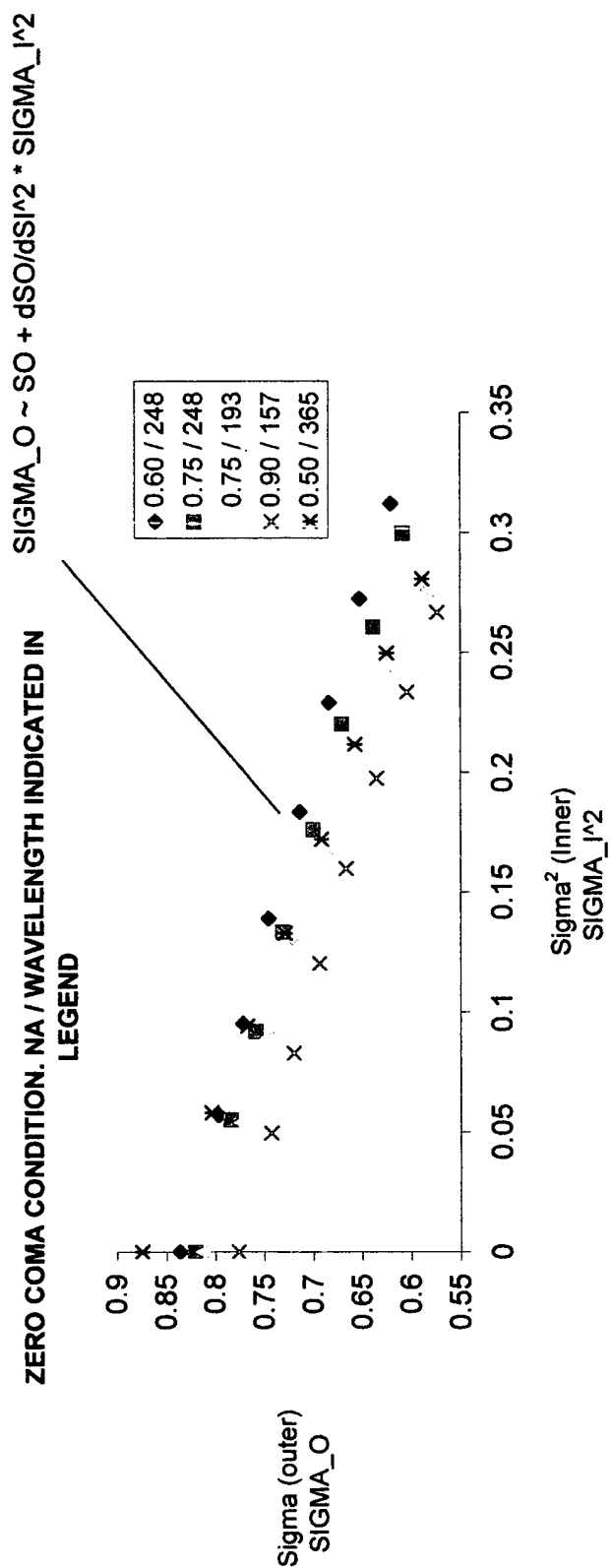


Figure 10a

Figure 10b

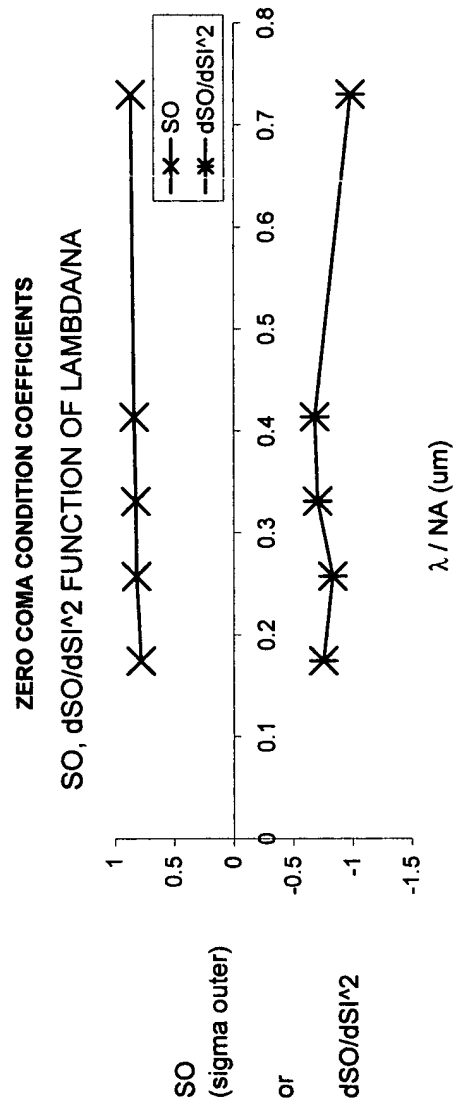


Figure 10c

FITTING COEFFICIENTS AS FUNCTION OF LAMBDA/NA					
LAMBDA/NA [UM]	LAMBDA	NA	SO	dSO/dSI^2	RSQ
0.73	365	0.5	0.8652	-0.9867	0.9989
0.413966667	248.38	0.6	0.8375	-0.6808	0.9989
0.331173333	248.38	0.75	0.8233	-0.706	0.9992
0.257333333	193	0.75	0.819	-0.833	0.9974
0.174444444	157	0.9	0.7813	-0.7539	0.9966

Figure 11b

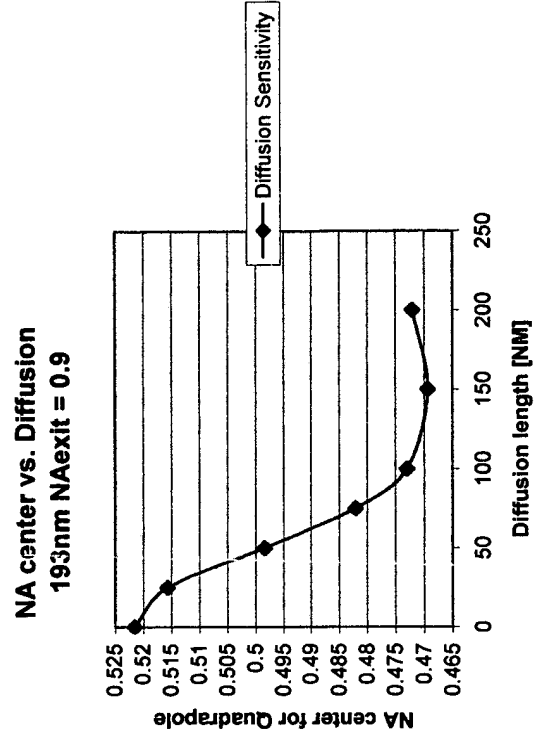
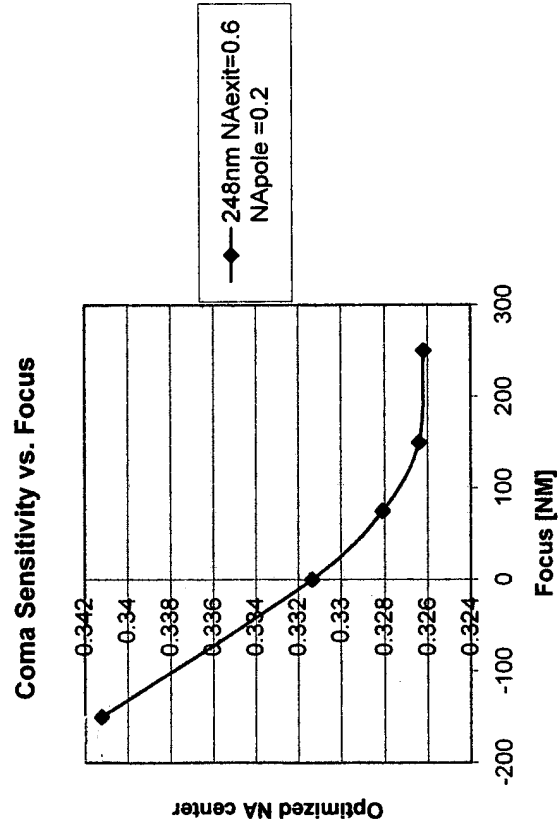


Figure 11a



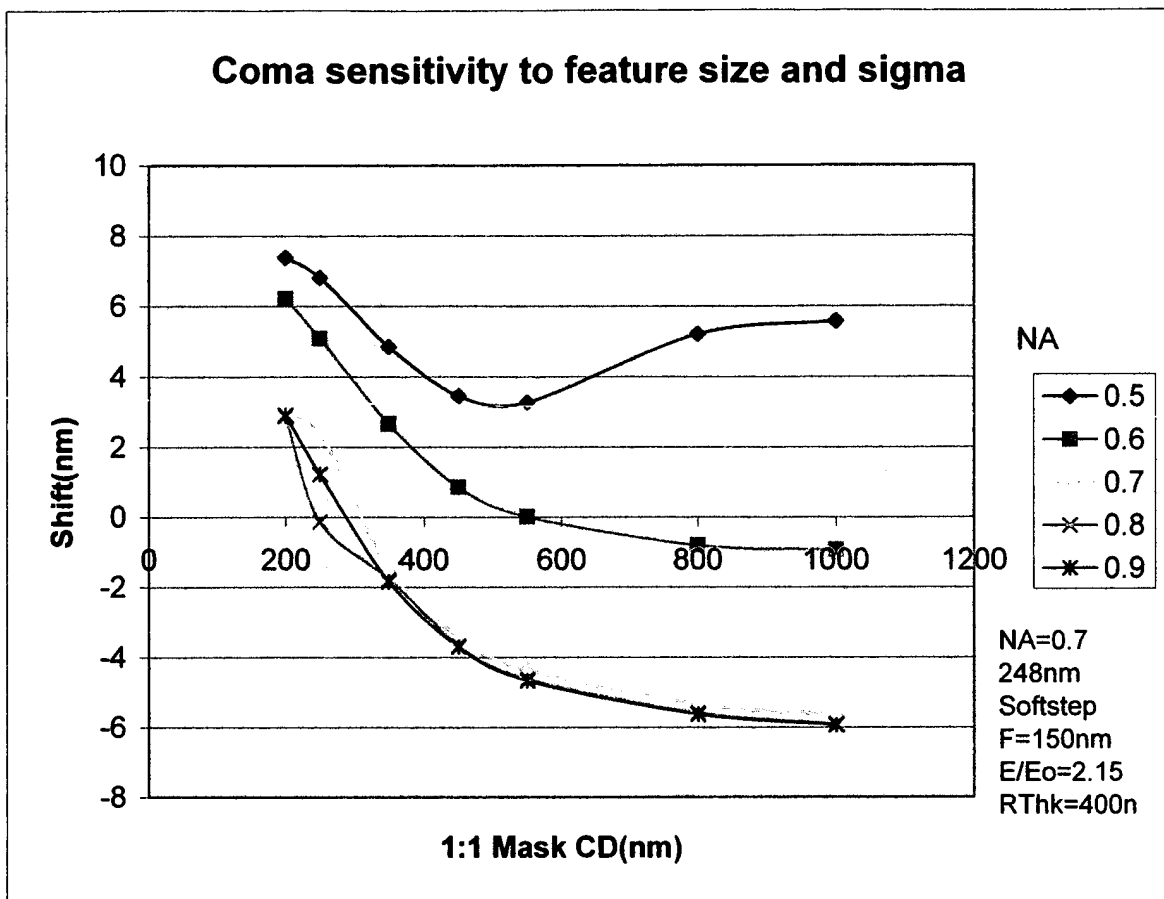


Figure 12

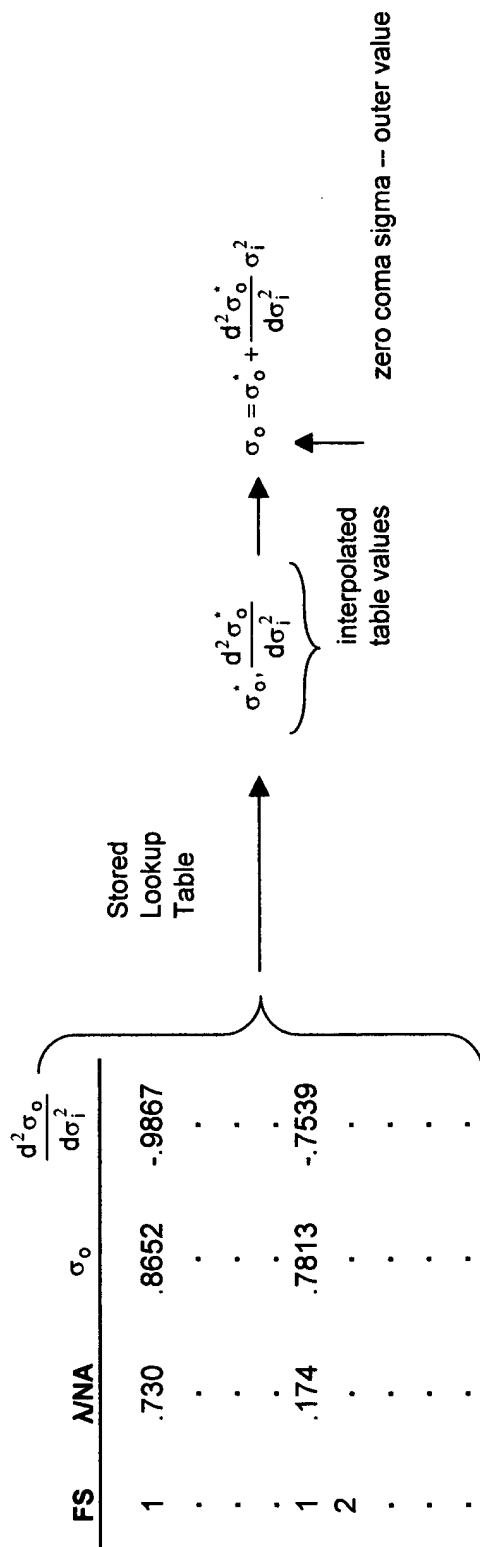


Figure 13

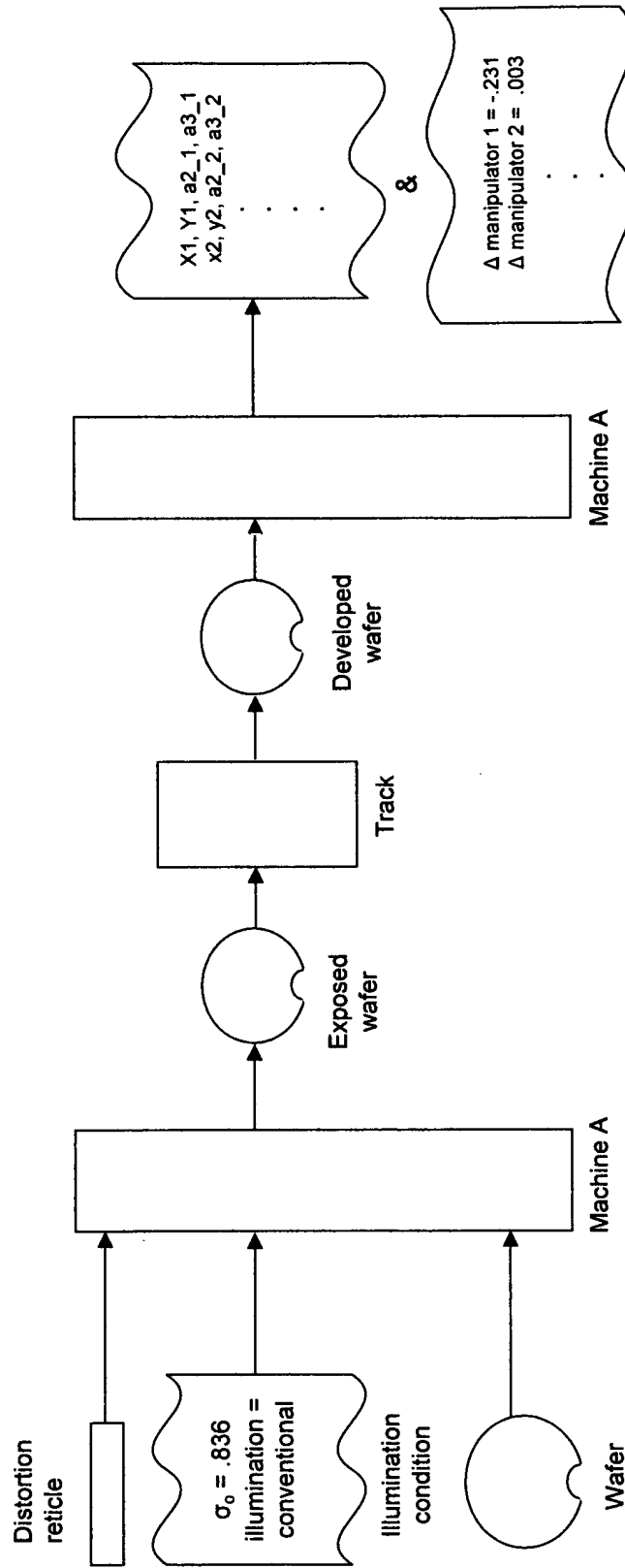


Figure 15

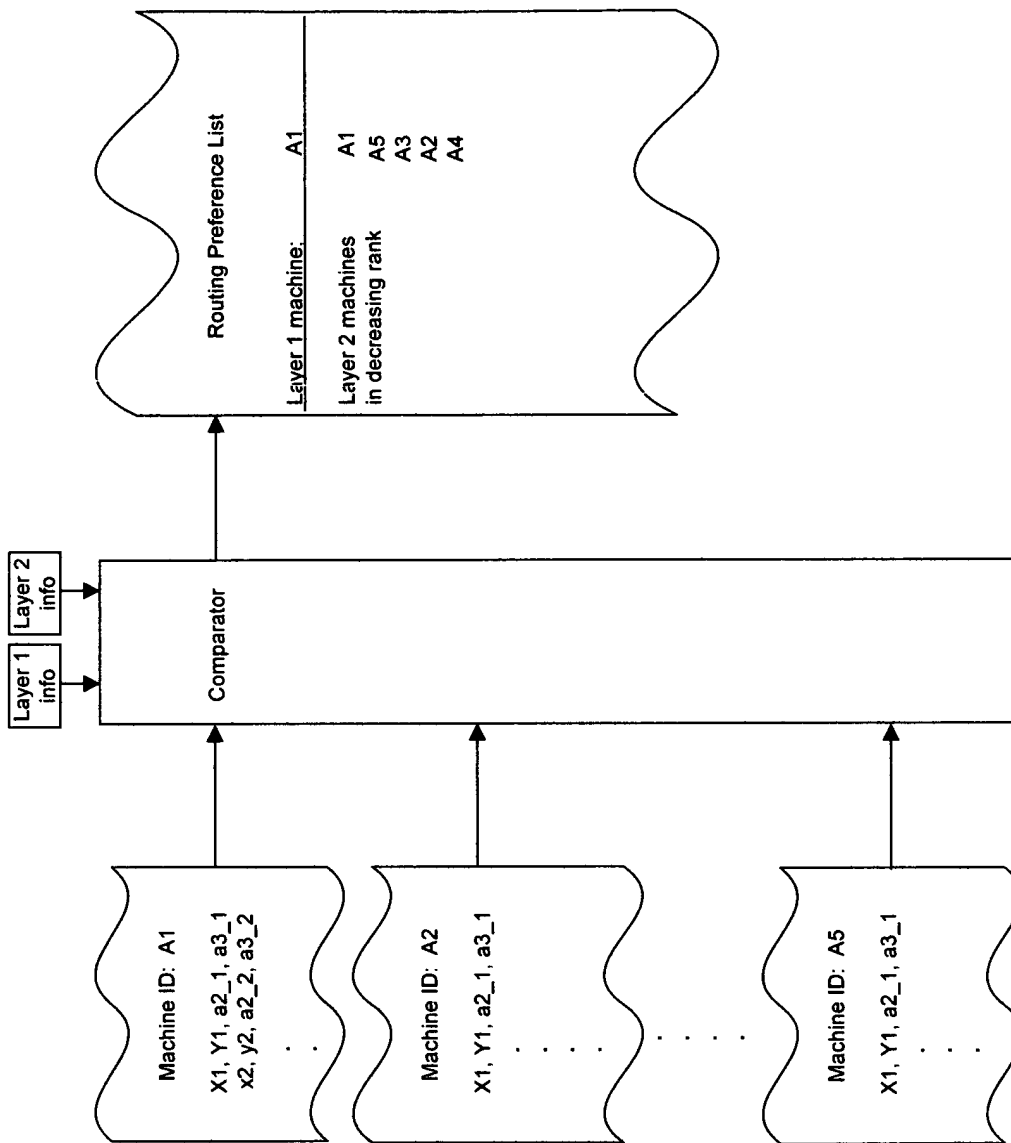


Figure 16